## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Taku HIRAYAMA et al.

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Serial No. NEW

Attorney Docket No. 2005\_0892A

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CHEMICAL-AMPLIFICATION TYPE SILICON-BASED POSITIVE-WORKING PHOTORESIST COMPOSITION [Corresponding to PCT/JP2003/015344 Filed December 1, 2003]

## PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows: